Characterization of Mono-crystalline Silicon from Rice Husk Ash

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Abstract — In this research, High purity silica was prepared by reflux raw rice husks (RRH) in oxalic acid which further removed the impurities, then burnt at 650°C for 3 hours. The aim of this research is characterisation of micro crystalline silicon production from rice husk ash. The obtained white ash was examined by XRD. Silicon was prepared by metallothermal reduction of pure silica at 650°C for 3 hours, using magnesium (99% purity) as a reducing agent. The results from X Ray Diffraction (XRD) patterns and Raman spectra indicated that the powder was micro crystalline silicon. The surface morphology of the powder was revealed by Scanning Electron Microscope (SEM) showing porosity due to acid leaching.

Index Terms: Micro crystalline Silicon, Rice Husk, Rice Husk Ash, Scanning Electron Microscope (SEM), Silica, X-Ray Diffraction (XRD), Raman Spectra

1. INTRODUCTION

The fluctuations of availability and feedstock cost determine the profitability of photovoltaic manufacturers, their production volume and expansion plans. The explosive growth of the solar cell industry has already driven up the price of electronic grade silicon and immediate solutions to the feedstock supply crunch is not clear [6]. Rice husk has been found to have a high content of hydrated silica from which silicon can be extracted. Silicon oxide is normally generated from sand that is extracted after a fusion of high temperature. Characterisation temperature was determined via the temperature at which the highest Specific Surface Area (SSA) and highest amount of silica were observed which was 700°C [8]. Presently, having no commercial value in itself, Rice Husks (RH) usually ends up being burned in open spaces, thus causing environmental pollution and disposal problems. Due to the need to conserve energy and resources, efforts have been made to burn the husk under controlled conditions and to utilize the resultant ash as building, semiconductor, composite, and abrasive materials [10]. Also, ash is an active catalyst and a good material for catalyst support because of its high surface area [2].

Rice husks are known to have a relatively high content of inorganic compounds. According to [11], depending on the soil content, some hazardous metal elements may be included in them. Combustion is the conventional technique for rice husk to exploit the calorific value and to obtain silica for commercial use, but cations such as K+, Al3+, P5+, Fe3+ and Mn can remain in rice husk ash (RHA) as oxides, decreasing its purity and further limiting its use. Moreover, in the direct combustion process of rice husk, the obtained rice husk ash consists of many black particles, which are very difficult to be fully burnt off. The high impurity of potassium (K) content is generally recognised to be the cause [6]. It produces high ash content, varying from 13 to 29wt % depending on the variety, climate and geographical location. The ash is largely composed of silica (87-97%) with small amounts of inorganic salts. Due to its high silica content, rice husk has become a source for preparation of a number of silicon compounds such as silicon carbide, and silicon nitride [3]. Its silica has fine particle size and high reactivity
 silica and is used to produce solar grade silicon. Nano-crystalline silicon (nc-Si), sometimes also known as microcrystalline silicon (μc-Si), is a form of porous silicon. It is an allotropically form of silicon with para-crystalline structure: which is similar to amorphous silicon (a-Si), in that it has an amorphous phase. Where they differ, however, is that nc-Si has small grains of crystalline silicon within the amorphous phase. This is in contrast to polycrystalline silicon (poly-Si) which consists solely of crystalline silicon grains, separated by grain boundaries. The difference comes solely from the grain size of the crystalline grains. Most materials with grains in the micrometer range are actually fine-grained poly-silicon, so nano-crystalline silicon is a better term. It has many useful advantages over a-Si, one being that if grown properly it can have higher electron mobility, due to the presence of the silicon crystallites. It also shows increased absorption in the red and infrared wavelengths, which make it an important material for use in a-Si solar cells. Its important advantage however, is that it has increased stability over amorphous-silicon, one of the reasons being because of its lower hydrogen concentration [9]. Demand and capacity of silicon production in tons is as shown in Figure 1.

Fig.1: Demand and capacity of silicon production in tons
Source: [7].

Microcrystalline silicon production is an attractive research for solar cell material application. The emphasis of this paper is to characterise the characterisation of microcrystalline silicon production from rice husk ash.

2. MATERIALS and METHODS

2.1 Purification of the Rice Husks

Raw Rice husks (RRH) collected from Osun State, Nigeria was thoroughly washed at least 4 times using distilled water and dried in an oven. The RRH was further refluxed with oxalic acid which removes the impurities present further. It was dried in the oven and used for further silica preparation. RRH was subjected to calcination at 700°C heating rate of 10°C/min and hold for 3h.

2.2 Preparation of High Purity Silica

The acid-treated RRH surface structure and surface morphology of silica was analysed via XRD and SEM.

2.3 Silicon Characterization

Metallothermal reduction process was employed for the preparation of silicon. Silica produced and Mg powders were homogeneously ground to obtained fine powder using agate mortar. The mixture was pyrolyzed in a tube furnace at 650°C for 3hour. A portion of the obtained brownish powder (as-reduced silica) was analysed by XRD and subsequently washed with HCl: H2O and HF: H2O. This is the leaching procedure adapted from [1] and [4]. The analysis of silicon was performed using XRD and Raman Spectra.

3. RESULTS and DISCUSSION

Fig.2 (a) shows the XRD of the observed silica, Fig. 2(b) and 2(c) show images taken by XRD and scanning electron microscope (SEM) of the silicon extracted from the Rice Husk Ash (RHA). SEM shows agglomerated particles vary in sizes confirming the tendency to cluster.
4. CONCLUSION

High purity silica (SiO₂) was prepared by reflux RRH in oxalic acid, and then pyrolyzed at 650°C for 3 hours. This silica was further used as a starting material for silicon (Si) preparation by metallothermal reduction process, using Mg as a reducing agent at 650°C for 3 hours. The obtained Si was analysed by XRD and confirmed by Raman spectra to be micro crystalline silicon. The prepared micro crystalline silicon was compared with the standard silicon.

5. REFERENCES


